

3-D Rarefied gas dynamics simulation software

RG3D

Outline

- **Under rarefied gas condition,**
Simulation software to solve a governing equation of molecular gas dynamics theory by probabilistic simulation method, DSMC(Direct Simulation Monte Carlo)method.
(Simulation method is same as DSMCM except mesh system)
- **Application**
 - Flow analysis for various vacuum chamber
 - Flow analysis for vacuum pump
 - Simulation of vacuum deposition
- **Feature**
 - Interface with NASTRAN format for mesh data
 - Many kinds of species with large difference in density can be simulated by Weight Algorithm
 - Fast Monte Carlo method under free molecule flow
 - Large mesh width can be taken by new collision method

Vacuum evaporation

Simulation of distribution of film thickness

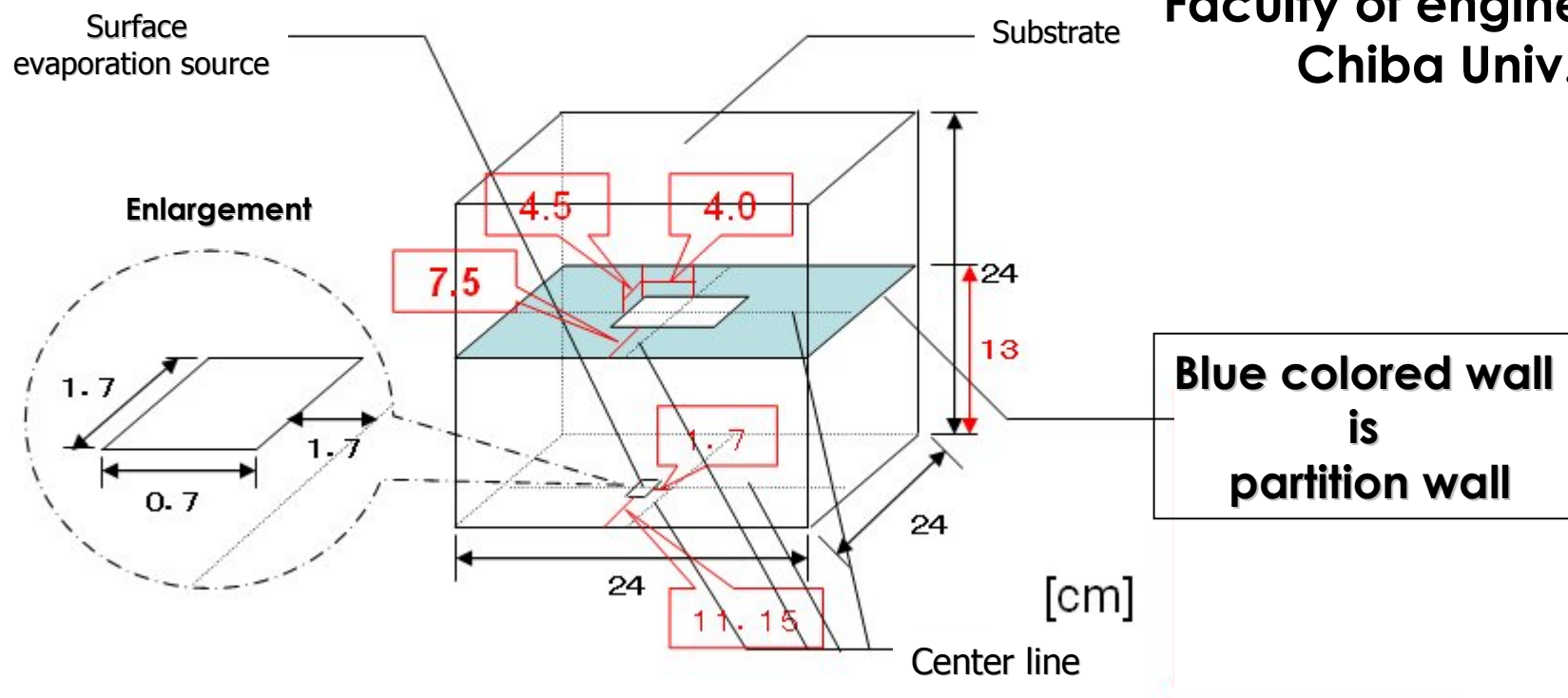
**Comparison with experiments regarding dependency of
Argon gas pressure**

Equipment and the other parameters

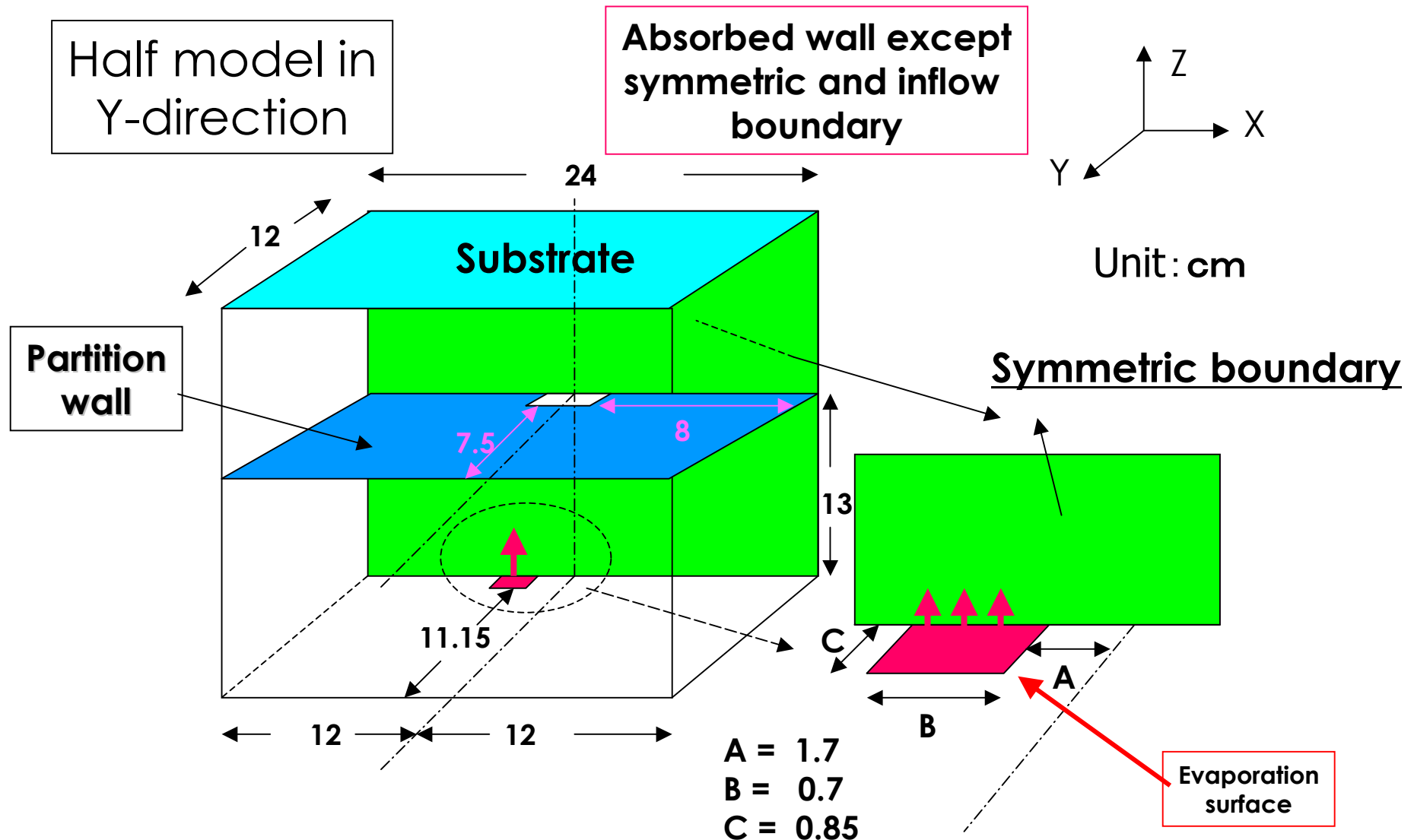
Mass : 197amu
Diameter : 174pm (1.74Å)
Temperature : 1400°C (1673 [K])
Flux : 0.874mg/sec (2.6565 X10¹⁸ [# /sec])

Experiment by
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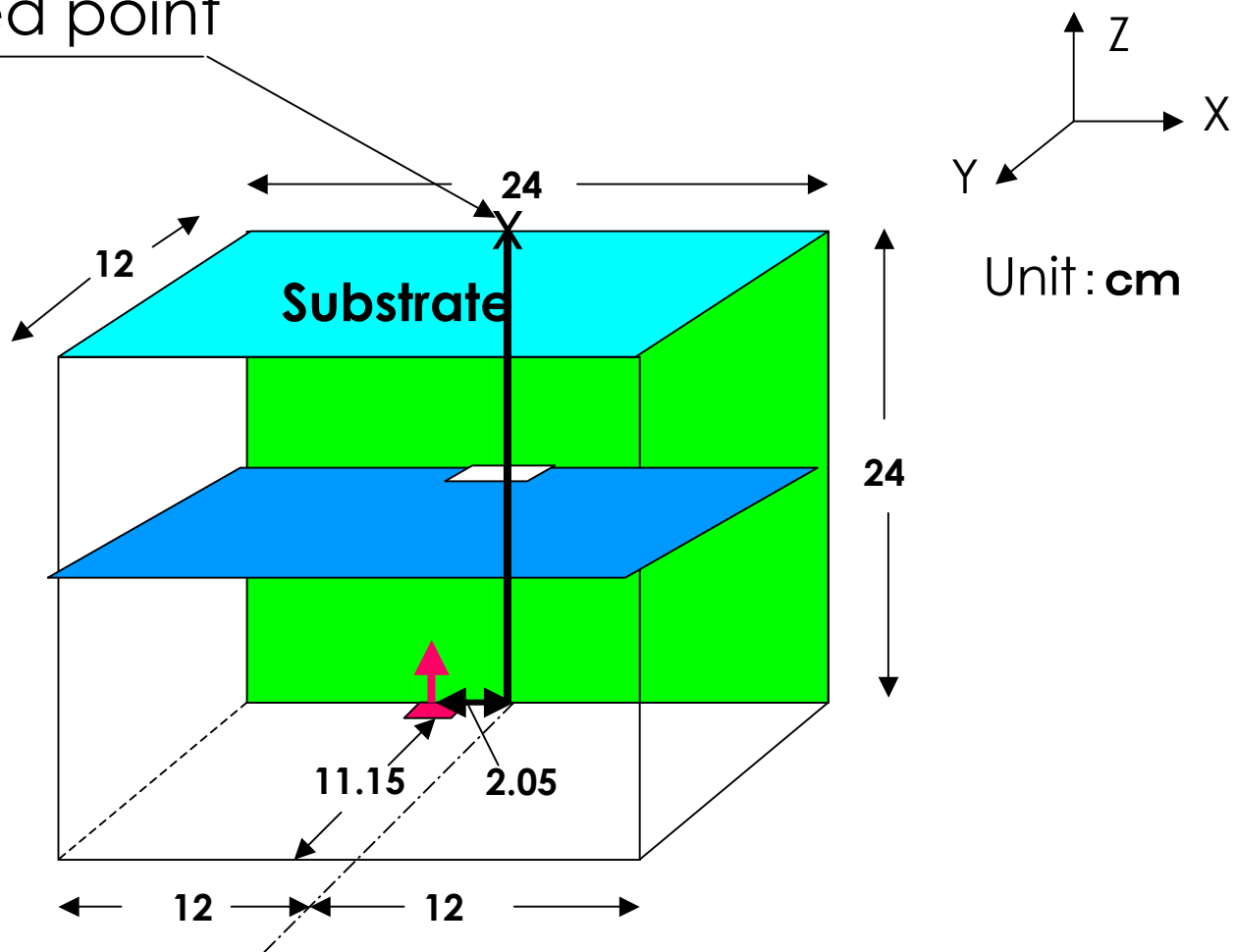


Computational model



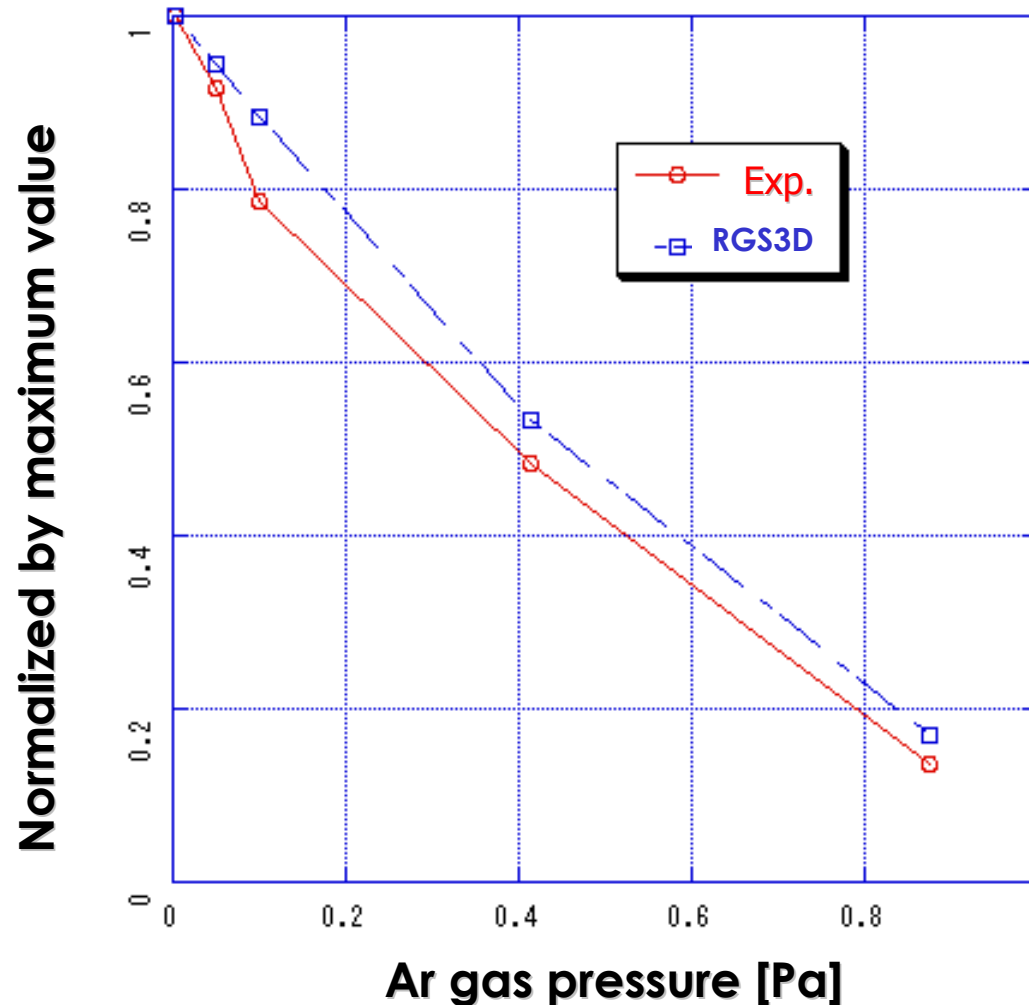
Observed point of film thickness

Observed point



Comparison with simulation and experiment of film thickness

Ar gas pressure dependency

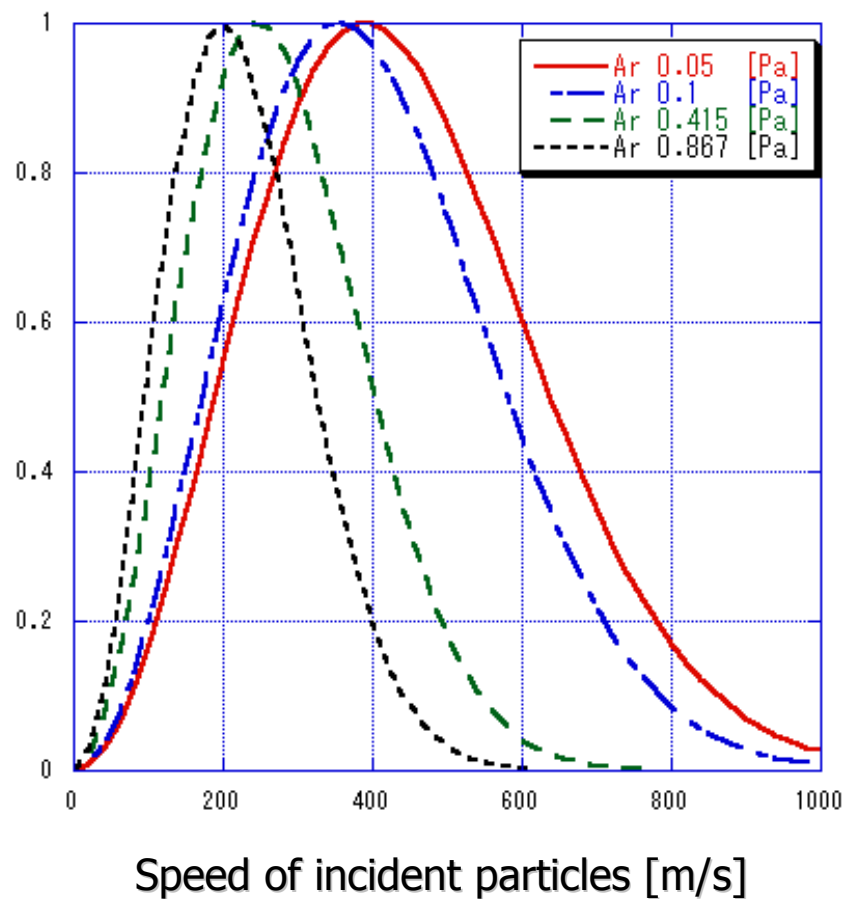


In this simulation, gas flow of Ar is neglected. So there are slightly differences.

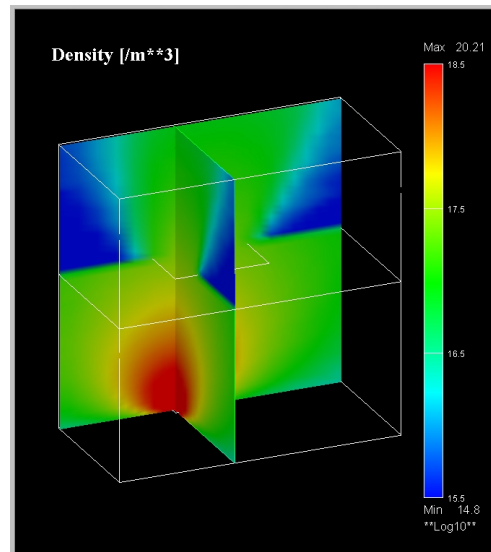


Distribution of speed of incident particles to substrate

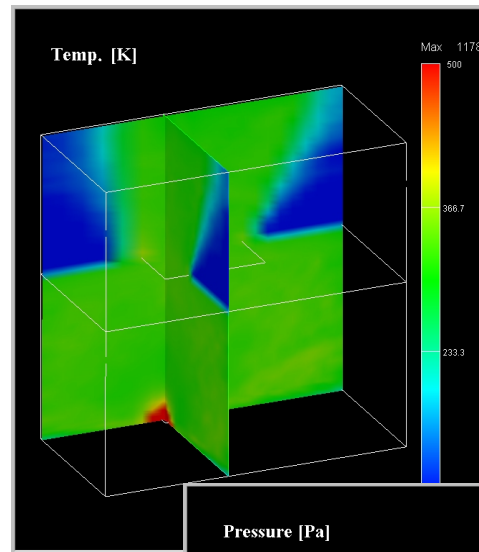
Frequency distribution of speed



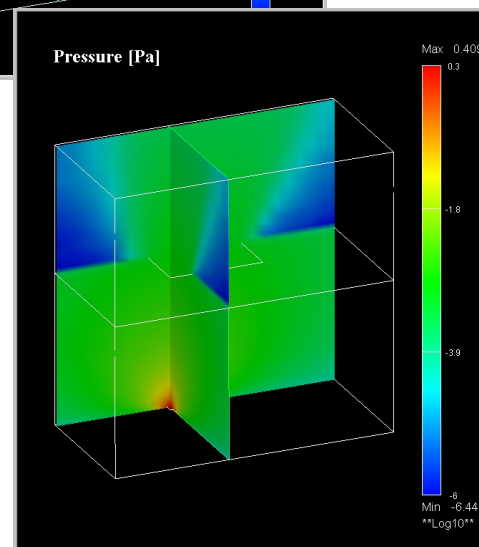
Spatial distribution of density, pressure, etc.



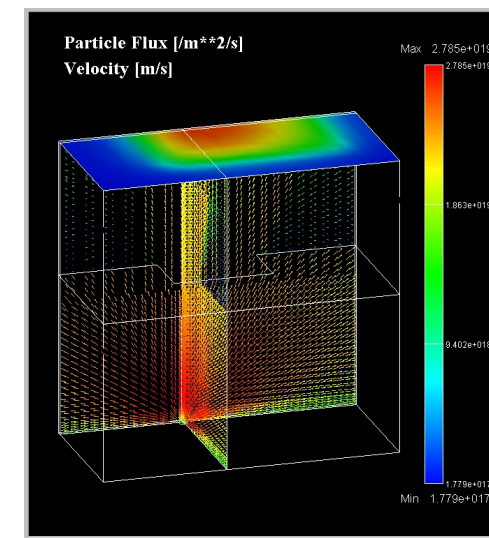
Density



Temperature



Pressure



Particle flux and Velocity